

AZ P4620 – run sheet

AZ Electronic Materials

nanyte.com/photoresists/az-p4620 · last updated 2026-07-26

Thickness: 6.9–14.8 μm

Softbake: 110 °C · 3 min · hotplate

Exposure dose – dose by film thickness · Ultratech 1500 gh-line stepper

Film thickness	Dose
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12 μm	893–927 mJ/cm^2
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24 μm	1574–1742 mJ/cm^2
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Exposure dose – dose by film thickness · Canon PLA-501F ghi-line contact aligner

Film thickness	Dose
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17 μm	630 mJ/cm^2
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Develop: Developer AZ 400K · Dilution 1:4 · Time 5 min · Method immersion